Excitonic States in MoS₂

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Excitons

- Bound states of electron and holes
- Two types:
- Frenkel
- Wannier-Mott



Frenkel Exciton

- Appears in materials with low dielectric constants (alkali halide crystals, organic molecular crystals, etc.)
- Low screening
- Binding Energy ~ 0.1 1 eV
- Bohr Radius ~ a few lattice constant

Wannier Exciton

• Appears in semiconductors

- High screening
- Binding Energy ~ 0.01 eV
- Bohr Radius ~ 10 100 × lattice constant

Excitons in Bulk Semiconductors

- Usually Wannier-type except in organic semiconductors
- Important in direct-band semiconductors e.g. III-V.
- Not much important in room temperature due to low binding energy (4 meV for GaAs)

Excitons in Lower Dimensions

 Considerably higher binding energy (~20 meV for typical quantum wells)

 Important optical effects in room temperature

Excitons in Graphene

- Free-standing graphene \rightarrow No gap \rightarrow No Exciton
- We have to make an energy gap
- Size Effect \rightarrow Graphene Nanoribbons
- Substrates (SiC, h-BN, etc.)

Excitons in Graphene

- Excitonic Effects in the Optical Spectra of Graphene Nanoribbons, L. Yang *et. Al.*, Nano Lett. 7, 3112 (2007)
- High exciton binding energy (~ 1 eV for AGNR with w ~ 1.2 nm)



Excitons in Graphene

Energy levels of exciton in a gapped graphene sheet, F. Fallah, M. Esmaeilzadeh, J. Appl. Phys. **114**, 073702 (2013).



 Exciton-related electroluminescence from monolayer MoS₂, Y. Ye, *et. al.*, arXiv:1305.4235 (2013).

• ~20 meV



- Excitonic Collapse in Semiconducting Transition Metal Dichalcogenides, A. S. Rodin and A. H. Castro Neto, arXiv: 1305.4278 (2013)
- Exciton states collapse into the continuum states in the strong coupling regime

$$H = at(\tau k_x \sigma_x + k_y \sigma_y) + \frac{\Delta}{2} \sigma_z - \lambda \tau \frac{\sigma_z - 1}{2} s_z$$
$$H_E = \begin{pmatrix} m_l & 2qe^{-i\theta} \\ 2qe^{i\theta} & -m_l \end{pmatrix} - \frac{\hbar v \alpha}{r}$$

$$\mathcal{E}_{jn} = m_l \frac{n + \sqrt{j^2 - \bar{\alpha}^2}}{\sqrt{\bar{\alpha}^2 + \left[n + \sqrt{j^2 - \bar{\alpha}^2}\right]^2}} \qquad m_{\pm} = (\Delta \mp \lambda \tau)/(2\tau)$$

• SiC substrate (with dielectric constant of 5.5)

 $\bar{\alpha} \approx 0.42$



 Effective lattice Hamiltonian for monolayer MoS2: Tailoring electronic structure with perpendicular electric and magnetic fields, H. Rostami, *et. Al.*, Phys. Rev. B 88, 085440 (2013)

$$H_{\tau s} = \frac{\Delta}{2} \sigma_z + \lambda \tau s \frac{1 - \sigma_z}{2} + t_0 a_0 \mathbf{q} \cdot \boldsymbol{\sigma}_\tau + \frac{\hbar^2 |\mathbf{q}|^2}{4m_0} (\alpha + \beta \sigma_z) + t_1 a_0^2 \mathbf{q} \cdot \boldsymbol{\sigma}_\tau^* \sigma_x \mathbf{q} \cdot \boldsymbol{\sigma}_\tau^*$$

- F. Fallah, R. Asgari (to be submitted)
- Effect of screening and non-zero β on excitonic states



- non-zero β
- Different screening
- Collapsing Effect Disappears!

Thank You